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***Integrated Optics: Devices,
Materials, and Technologies XIV***

**Jean-Emmanuel Broquin
Christoph M. Greiner**
Editors

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Contents

- ix *Conference Committee*
xi *Introduction*

SESSION 1 WAVEGUIDE ENGINEERING I

- 7604 02 **Integrated photonic devices for advanced modulation formats (Invited Paper)** [7604-01]
Y. Hibino, NTT Corp. (Japan)
- 7604 03 **High performance optical waveguides based on boron and phosphorous doped silicon oxynitride** [7604-02]
F. Sun, A. Driessen, K. Wörhoff, Univ. of Twente (Netherlands)
- 7604 04 **Accessing diamond waveguides and future applications** [7604-03]
M. P. Hiscocks, The Univ. of New South Wales (Australia); C.-H. Su, K. Ganesan, B. C. Gibson, A. D. Greentree, L. C. L. Hollenberg, The Univ. of Melbourne (Australia); F. Ladouceur, The Univ. of New South Wales (Australia); S. Praver, The Univ. of Melbourne (Australia)
- 7604 05 **Waveguides based on TeGe thick films for spatial interferometry** [7604-04]
E. Barthélémy, S. Albert, C. Vigreux, A. Pradel, Institut Charles Gerhardt, Univ. Montpellier 2 (France); X.-H. Zhang, S. Zhang, Sciences Chimiques de Rennes, Univ. de Rennes 1 (France); G. Parent, Lab. d'Energétique et de Mécanique Théorique et Appliquée (France); T. Billeton, Lab. de Physique des Lasers, Univ. Paris Nord (France); J.-E. Broquin, Institut de Microélectronique, Electromagnétique et Photonique (France); S. Ménard, M. Barillot, Thales Alenia Space (France); V. Kirschner, European Space Agency (Netherlands)
- 7604 06 **Fabrication and characterization of $As_2S_3/Y_3Fe_5O_{12}$ and $Y_3Fe_5O_{12}/SOI$ strip-loaded waveguides for integrated optical isolator applications** [7604-05]
L. Bi, J. Hu, L. Kimerling, C. A. Ross, Massachusetts Institute of Technology (United States)
- 7604 07 **Microfluidics and thin-film processes: a recipe for organic integrated photonics based on 3D microresonators** [7604-06]
N. Huby, D. Pluchon, M. Belloul, A. Moreac, Institute of Physics of Rennes, CNRS, Univ. de Rennes 1 (France); N. Coulon, Institute of Electronics and Telecommunications, CNRS, Univ. de Rennes 1 (France); E. Gaviot, Lab. of Acoustics, CNRS, Univ. du Maine (France); P. Panizza, B. Bêche, Institute of Physics of Rennes, CNRS, Univ. de Rennes 1 (France)

SESSION 2 AMPLIFIERS AND LASERS

- 7604 08 **Rare-earth-ion-doped Al_2O_3 for integrated optical amplification (Invited Paper)** [7604-07]
K. Wörhoff, J. D. B. Bradley, L. Agazzi, M. Pollnau, Univ. of Twente (Netherlands)
- 7604 0A **Optofluidic FRET dye laser controlled by DNA scaffolds** [7604-09]
Y. Sun, C.-S. Wu, X. Fan, Univ. of Missouri, Columbia (United States)

- 7604 0C **Low threshold Er³⁺/Yb³⁺ co-doped microcavity laser** [7604-11]
H.-S. Hsu, The Univ. of Southern California (United States); C. Cai, California Institute of Technology (United States); A. M. Armani, The Univ. of Southern California (United States)

SESSION 3 MODELLING

- 7604 0D **Large scale simulations in the realm of nanooptics (Invited Paper)** [7604-12]
C. Rockstuhl, C. Etrich, C. Helgert, C. Menzel, T. Paul, S. Fahr, T. Pertsch, Friedrich-Schiller-Univ. Jena (Germany); J. Dormüller, R. Esteban, W. Khunsin, R. Vogelgesang, K. Kern, Max-Planck-Institut für Festkörperforschung (Germany); A. Dmitriev, Chalmers Univ. of Technology (Sweden); K. Bittkau, T. Beckers, R. Carius, Forschungszentrum Jülich GmbH (Germany); F. Lederer, Friedrich-Schiller-Univ. Jena (Germany)
- 7604 0F **Finite element method for accurate 3D simulation of plasmonic waveguides** [7604-14]
S. Burger, L. Zschiedrich, J. Pomplun, F. Schmidt, Zuse Institute Berlin (Germany) and JCMwave GmbH (Germany)
- 7604 0G **Partial image revivals in a multi-channel directional-coupler** [7604-15]
R. J. McCosker, G. E. Town, Macquarie Univ. (Australia)

SESSION 4 PHOTONIC INTEGRATION

- 7604 0I **Generic packaging concepts in the frame of network of excellence ePIXnet** [7604-17]
T. Tekin, L. Zimmermann, Technische Univ. Berlin (Germany); H. Schröder, Fraunhofer IZM (Germany); P. Dumon, W. Bogaerts, Ghent Univ. (Belgium); J. V. Galan, P. Sanchis, Univ. Politécnic de Valencia (Spain); W. Whelan-Curfin, D. Beggs, Univ. of St. Andrews (United Kingdom)
- 7604 0J **Quantum well intermixing in AlInGaAs MQW structures through impurity-free vacancy method** [7604-18]
K.-H. Lee, J. O'Callaghan, B. Roycroft, Tyndall National Institute (Ireland); C. L. L. M. Daunt, Tyndall National Institute (Ireland) and Univ. College Cork (Ireland); H. Yang, J. H. Song, Tyndall National Institute (Ireland); F. H. Peters, Tyndall National Institute (Ireland) and Univ. College Cork (Ireland); B. Corbett, Tyndall National Institute (Ireland)
- 7604 0K **Monolithic integration of optical mode-size converter and high-speed electroabsorption modulators using laterally undercut waveguide** [7604-19]
T.-H. Wu, F.-Z. Lin, H.-J. Yan, J.-P. Wu, Y.-J. Chiu, National Sun Yat-Sen Univ. (Taiwan)

SESSION 5 SUBWAVELENGTH/DIFFRACTIVE PHOTONICS

- 7604 0M **Leaky-mode resonance photonics: technology for biosensors, optical components, MEMS, and plasmonics (Invited Paper)** [7604-21]
R. Magnusson, The Univ. of Texas at Arlington (United States) and Resonant Sensors Inc. (United States); D. Wawro, S. Zimmerman, Y. Ding, Resonant Sensors Inc. (United States); M. Shokooh-Saremi, The Univ. of Texas at Arlington (United States); K. J. Lee, Univ. of Connecticut (United States); D. Ussery, The Univ. of Texas at Arlington (United States); S. Kim, Ajou Univ. (Korea, Republic of); S. H. Song, Hanyang Univ. (Korea, Republic of)

- 7604 0N **High speed optical filtering using active resonant subwavelength gratings** [7604-22]
A. V. Gin, S. A. Kemme, R. R. Boye, D. W. Peters, J. F. Ihlefeld, R. D. Briggs, J. R. Wendt, A. R. Ellis, L. H. Marshall, Sandia National Labs. (United States); T. R. Carter, J. D. Hunker, Sandia Staffing Alliance (United States); S. Samora, LMATA Government Services LLC (United States)
- 7604 0O **Deep-subwavelength focusing and steering of light in an aperiodic metallic waveguide array** [7604-23]
L. Verslegers, P. B. Catrysse, Z. Yu, S. Fan, Stanford Univ. (United States)
- 7604 0P **Application of resonant subwavelength gratings to a rotary position encoder** [7604-24]
R. R. Boye, D. W. Peters, J. R. Wendt, R. J. Shul, Sandia National Labs. (United States); S. Samora, S. G. Rich, LMATA Government Services, LLC (United States); T. Carter, Sandia Staffing Alliance, LLC (United States); A. L. Lentine, R. A. Kellogg, S. A. Kemme, Sandia National Labs. (United States)

SESSION 6 NON-LINEAR DEVICES AND MODULATORS

- 7604 0R **Towards nonlinear photonic wires in lithium niobate (Invited Paper)** [7604-26]
H. Hu, L. Gui, R. Ricken, W. Sohler, Univ. Paderborn (Germany)
- 7604 0U **High-density integrated optics in ion-sliced lithium niobate thin films** [7604-29]
G. Poberaj, M. Koechlin, F. Sulser, P. Günter, ETH Zürich (Switzerland)

SESSION 7 WAVEGUIDE ENGINEERING II

- 7604 0V **Review: Tg - reversible glass door to fabrication of photonic devices and integrated circuits** [7604-30]
A. B. Seddon, D. Furniss, Z. G. Lian, W. J. Pan, T. M. Benson, The Univ. of Nottingham (United Kingdom)
- 7604 0W **Fabrication and optimization of Tantalum pentoxide waveguides for optical micro-propulsion** [7604-31]
B. S. Ahluwalia, O. G. Hellesø, Univ. of Tromsø (Norway); A. Z. Subramanian, N. M. B. Perney, N. P. Sessions, J. S. Wilkinson, Univ. of Southampton (United Kingdom)
- 7604 0X **Fabrication of buried-type waveguide with optical gates by nano ion-exchange method** [7604-32]
T. Yano, E. Shokatsu, Tokyo Institute of Technology (Japan); H. Segawa, National Institute for Materials Science (Japan); S. Shibata, Tokyo Institute of Technology (Japan)
- 7604 0Y **Refractive index engineering by fast ion implantations: a generic method for constructing multi-components electro-optical circuits** [7604-33]
A. J. Agranat, A. Gumennik, H. Ilan, The Hebrew Univ. of Jerusalem (Israel)
- 7604 0Z **Highly photorefractive Eu³⁺ activated sol-gel SiO₂-SnO₂ thin film waveguides** [7604-34]
S. Berneschi, IFAC-CNR (Italy); S. N. B. Bhaktha, LPMC, CNRS, Univ. de Nice-Sophia Antipolis (France); A. Chiappini, A. Chiasera, M. Ferrari, IFN-CNR (Italy); C. Kinowski, S. Turrell, LASIR, CNRS, Univ. des Sciences et Technologies de Lille (France); C. Trono, M. Brenci, I. Cacciari, G. Nunzi Conti, S. Pelli, G. C. Righini, IFAC-CNR (Italy)

SESSION 8 SENSING

- 7604 10 **Enhanced fluorescence sensing with nano-apertures (Invited Paper)** [7604-35]
M. Diwekar, S. Attavar, S. Blair, The Univ. of Utah (United States); M. Davis, E. Gardner, MOXTEK, Inc. (United States)
- 7604 11 **Realization of a NIR compact static Fourier transform spectrometer in glass integrated optics** [7604-36]
B. Martin, A. Morand, IMEP-LAHC (France); L. Jocou, LAOG (France); P. Benech, G. Grosa, IMEP-LAHC (France); E. Le Coarer, P. Kern, LAOG (France)
- 7604 12 **Design of metamaterial based sensors for pressure measurement** [7604-37]
R. Aylo, P. P. Banerjee, Univ. of Dayton (United States); A. K. Ghosh, P. Verma, Univ. of Oklahoma (United States)
- 7604 13 **Fiber-based optical Fabry-Pérot gas sensor for fast and on-column detection** [7604-38]
J. Liu, Y. Sun, Univ. of Missouri, Columbia (United States); G. Frye-Mason, Consultant (United States); A. K. Thompson, S. Ja, ICx Nomadics, Inc. (United States); X. Fan, Univ. of Missouri, Columbia (United States)
- 7604 14 **Stationary Wave Integrated Fourier Transform Spectrometer (SWIFTS)** [7604-39]
J. Ferrand, LAOG, UJF-CNRS (France); G. Custillon, IMEP-LAHC, INPG-UJF-CNRS (France); G. Leblond, LNIO, UTT (France); F. Thomas, T. Moulin, E. le Coarer, LAOG, UJF-CNRS (France); A. Morand, IMEP-LAHC, INPG-UJF-CNRS (France); S. Blaize, LNIO, UTT (France); T. Gonthiez, Flordalis (France); P. Benech, IMEP-LAHC, INPG-UJF-CNRS (France)
- 7604 15 **Integrated optical chip in fiber optic gyros** [7604-40]
V. Chunduru, R. VaraLakshmi, Dhanunjay, Karthik, Osmania Univ. (India)

SESSION 9 PLASMONICS I

- 7604 17 **Experimental characterization of dispersion in plasmonic nanostripes for integrated DNA sensing** [7604-42]
P. Steinvurzel, Harvard Univ. (United States); T. Yang, Harvard Univ. (United States) and Univ. of Michigan - Shanghai Jiao Tong Univ. Joint Institute (China); K. B. Crozier, Harvard Univ. (United States)
- 7604 18 **Guided subwavelength optical mode with slow group velocity supported by a periodic plasmonic waveguide** [7604-47]
L. Yang, C. Min, G. Veronis, Louisiana State Univ. (United States)
- 7604 19 **Nanoplasmonic couplers and modulators based on metal-insulator-metal structures** [7604-44]
Z. Lu, R. Yang, R. A. Wahsheh, M. A. G. Abushagur, Rochester Institute of Technology (United States)

SESSION 10 PLASMONICS II

- 7604 1B **Manipulation of near field polarization by far field excitation** [7604-46]
S.-Y. Chen, A. A. Lazarides, Duke Univ. (United States)

7604 1C **Efficient sensitivity analysis of surface plasmon waveguide structures** [7604-43]
M. A. Swillam, M. H. Bakr, X. Li, McMaster Univ. (Canada)

POSTER SESSION

7604 1D **Detailed observation of optical intensity and frequency signal transmission in random metal-dielectric film** [7604-48]
M. Fukuda, K. Yamaguchi, Toyohashi Univ. of Technology (Japan)

7604 1F **Label-free biosensors with enhanced sensitivity based on polymer waveguide Bragg reflectors** [7604-50]
J.-W. Kim, K.-J. Kim, M.-C. Oh, Pusan National Univ. (Korea, Republic of)

Author Index

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- 3 Modelling
Christoph A. Wächter, Fraunhofer-Institut für Angewandte Optik und
Feinmechanik (Germany)
- 4 Photonic Integration
Stefano Taccheo, Swansea University (United Kingdom)
- 5 Subwavelength/Diffractive Photonics
Christoph M. Greiner, LightSmyth Technologies, Inc. (United States)
- 6 Non-Linear Devices and Modulators
Jens H. Schmid, Canadian Photonics Fabrication Centre (Canada)
- 7 Waveguide Engineering II
Yakov Sidorin, Quarles Brady LLP (United States)
- 8 Sensing
Xudong Fan, University of Missouri, Columbia (United States)
- 9 Plasmonics I
Pierre Berini, University of Ottawa (Canada)
- 10 Plasmonics II
Robert L. Nelson, Air Force Research Laboratory (United States)

Introduction

Since the concept of Integrated Optics was introduced by Miller in 1969, this field of research has kept evolving year after year, renewing itself constantly and, sometimes, surprisingly. Indeed, though the telecom bubble exploded, Integrated Optics kept on moving, finding applications in sensors and bio-chips but also in fields that may appear unlikely upon first glance, such as Astronomy.

This wealth of Integrated Optics applications is accompanied by a great breadth of technological and design approaches. From the well-known "Silica-on silicon" based waveguides to new plasmonic devices, from microresonators to diffractive devices, the conference Integrated Optics: Devices, Materials, and Technologies has been trying to reflect the vitality and the diversity of this field. In these proceedings, the reader will therefore see new advanced work on diamond waveguides and mid-infrared waveguides, as well as the "re-invention" of Lithium Niobate devices thanks to the use of ion-slicing.

The reader will find articles written by students, who quite often gave their first international talk at this conference, together with papers from renowned scientists of the field. It is indeed because today's students are tomorrow's scientific leaders that our conference has a long-standing tradition of promoting their participation and will keep on doing so, enabled by the generous SPIE student grant policy.

If Integrated Optics: Devices, Materials, and Technologies is now one of the oldest conferences of the SPIE Optoelectronics symposium, it is, on one hand, due to the high quality of the scientific work that has been presented throughout the years, and, on the other hand, it is also due to the dedication of its program committee members who willingly spend part of their summertime building the conference and finding the exciting invited talks that we see every year. To them, to the speakers and authors, and to the SPIE staff that makes the logistics run so smoothly, we would like to express our gratitude. We are looking forward to seeing you next year!

Jean-Emmanuel Broquin
Christoph M. Greiner

